# Preliminary results on monolithic CMOS sensors with gain layer in 110 nm technology for the ALICE 3 experiment



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## **Context and motivation: the ALICE 3 upgrade**

Monolithic Active Pixel Sensors (MAPS) based on the CMOS Imaging Sensor (CIS) technology are used in ultra-light large tracking systems of various high-energy physics (HEP) experiments like ALICE (A Large Ion Collider Experiment) at the CERN LHC. They are considered for many future HEP applications, in particular for ALICE 3, the next-generation heavy-ion physics experiment proposed for the LHC Run 5 and 6.









ALICE 3 TOF detector: dedicated to Time Of Flight measurements. The required time resolution of 20 ps will provide accurate particle identification information. Other TOF requirements: material budget 1-3%  $X_0$  per layer, power consumption limit: 50 mW/cm<sup>2</sup>

## The sensor concept

Different silicon-based technologies are under study for the ALICE 3 timing layer: LGAD, SPAD or MAPS with gain. Timing with silicon sensors:  $\sigma_t^2 = \sigma_{\text{Time Walk}}^2 + \sigma_{\text{Landau Noise}}^2 + \sigma_{\text{Distortion}}^2 + \sigma_{\text{Jitter}}^2 + \sigma_{\text{TDC}}^2$ 

Structures developed by the **ARCADIA** (Advanced Readout **C**MOS Architectures with Depleted Integrated sensor Arrays) collaboration: LFoundry 110 CIS technology





#### Arcadia pad sensor

#### Arcadia pad sensor with gain

Additional p-gain implant below the n+ collecting electrode to improve the time performance Different sensor layouts to test the charge collection properties at borders: A1 and A2

PW NW PV

- no space between deep-p-well and p-gain





## MadPix : a Monolithic CMOS Avalanche Detector PIXelated

First prototype with integrated electronics and gain layer

► Active thickness: 48 µm

ightarrow V<sub>back</sub> allows full depletion (-25 V ÷ -40 V)  $\rightarrow$  drift field in the substrate  $\mathbf{V}_{top}$  (30 V ÷ 50 V)  $\rightarrow$  defines the gain







## Laboratory measurements

Optical characterization of passive structures at University of Trento ► IR laser from the back of the sensor simulating the passage of a MIP laser spot ~ 20 µm



TCAD simulations to investigate the p-gain profile mismatch

Implantation energy lower by 30% with respect to the design



Each side has 4 matrices of 64 pixels divided in 8

rows and 8 columns

 $\blacktriangleright$  Pixels size: 100 µm x 250 µm

Maximum applicable backside voltage limited by punch-through current (power consumption increases exponentially above a certain threshold)

Future plans: test beam and laboratory measurements

Validation of MadPix + LIROC (front-end ASIC designed to discriminate SiPM signals) + **picoTDC** (resolution of 3 - 12 ps)  $\rightarrow$  acquisition of 4 analog outputs Validation of **MadPix + picoTDC** to acquire 4 discriminated outputs Electrical and optical characterization of the monolithic devices with higher gain and test beam to evaluate the timing resolution (foreseen in July 2024)



### In-beam measurements

Proton Synchrotron - CERN, October 2023  $p/\pi$  beam with momentum 10 GeV/c setup in collaboration with INFN Bologna MadPix read out via 3 oscilloscope channels





MadPix (DUT) LGAD (trigger plane)

